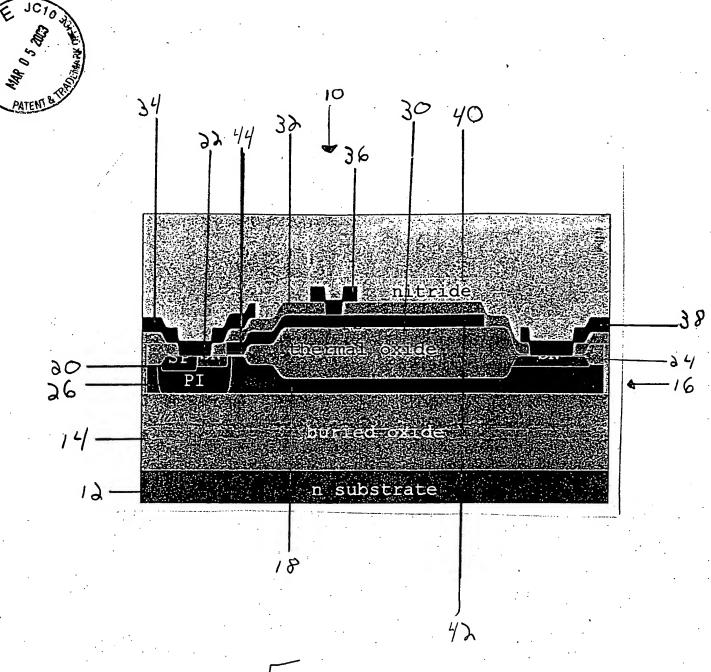
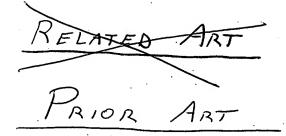
SUBMISSION OF PROPOSED DRAWING AMENDMENT FOR APPROVAL BY EXAMINER (37 CFR 1.121(a)(3)(ii) or 37 CFR 1.121(b)(3)(ii)) Docket No. PHUS010610			
In Re Application Of: 1	Letavic et al.	MAR 0 5 2003	
Serial No.	Filing Date	Examiner Examiner	Ant Unit
10/015,847	12/10/2001	Lewis, M.	2822
Invention: DUAL GATE OXIDE HIGH-VOLTAGE SEMICONDUCTOR DEVICE (as Amended)			
Address to: Assistant Commissioner for Patents Washington, D.C. 20231			
Attached please find:			
(check applicable items)			
☐ a sketch in permanent ink			
a copy of the original drawing(s) with red ink			
showing proposed changes to the drawing(s) in this application for which the approval of the examinar is requested. RECEIVED Dated: February 28, 2003			
	lephone	on 2/28/2003 first class mail under	with the U.S. Postal Service as 37 C.F.R. 1.8 and is addressed to the oner for Patents, Washington, D.C.
		Signature of F	Person Mailing Correspondence

Wendy E. Thompson

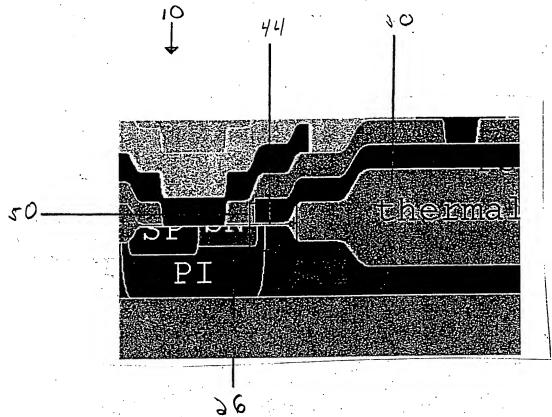
Typed or Printed Name of Person Mailing Correspondence



F16.1







F16 2

